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Siqun Xiao is Director for Business development at FEI Company in China. He received his B.S. in materials science and engineering from Zhejiang University 1982 in China, his M.S. in metallurgy from RWTH Aachen 1986 and Ph. D. in physics from University of Goettingen 1990 in Germany. 1990-1993 he was Sr. Research Associate in the department of materials science and engineering at Case Western Reserve University in Cleveland. He became post-doctoral fellow at the National Center for Electron Microscopy of Lawrence Berkeley Lab, Berkeley, USA in 1993-1996. During 1997-2003 he held various positions at Kla-Tencor including demo manager for wafer inspection division, applications manager for TSMC account and applications manager for China. Before joining FEI in 2004-2010 he worked at Applied Materials as its China Account General Manager for the Process Diagnostic and Control Division. Authored and co-authored over 60 publications mainly in the field of transmission electron microscopy, phase transformation, the crystallography, thermodynamics and kinetics of precipitation in metals and ceramics.